

Special Issue

Sensing for In-Process Monitoring of High-Value Manufacturing Processes

Message from the Guest Editors

This Special Issue aims to bring together research relating to sensing for in-process monitoring of high-value manufacturing processes. We invite you to contribute to this issue by submitting both case studies and research articles focusing on high-value manufacturing processes. This Special Issue will cover papers from a range of manufacturing processes including (but not limited to): surface manufacturing, machining, assembly, and continuous manufacturing. We particularly welcome papers from high-value manufacturing application areas, such as electrical machine manufacture, aerospace assembly, and surface manufacture.

Guest Editors

Prof. Dr. Ashutosh Tiwari

Prof. Geraint Jewell

Dr. Divya Tiwari

Dr. Michael Farnsworth

Deadline for manuscript submissions

closed (20 February 2023)



Sensors

an Open Access Journal
by MDPI

Impact Factor 3.5
CiteScore 8.2
Indexed in PubMed



mdpi.com/si/69515

Sensors
Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34
sensors@mdpi.com

[mdpi.com/journal/
sensors](https://mdpi.com/journal/sensors)





Sensors

an Open Access Journal
by MDPI

Impact Factor 3.5
CiteScore 8.2
Indexed in PubMed



[mdpi.com/journal/
sensors](https://mdpi.com/journal/sensors)



About the Journal

Message from the Editor-in-Chief

Sensors is a leading journal devoted to fast publication of the latest achievements of technological developments and scientific research in the huge area of physical, chemical and biochemical sensors, including remote sensing and sensor networks. Both experimental and theoretical papers are published, including all aspects of sensor design, technology, proof of concept and application. Sensors organizes Special Issues devoted to specific sensing areas and applications each year.

Editor-in-Chief

Prof. Dr. Vittorio M. N. Passaro

Dipartimento di Ingegneria Elettrica e dell'Informazione (Department of Electrical and Information Engineering), Politecnico di Bari, Via Edoardo Orabona n. 4, 70125 Bari, Italy

Author Benefits

Open Access:

free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility:

indexed within Scopus, SCIE (Web of Science), PubMed, MEDLINE, PMC, Ei Compendex, Inspec, Astrophysics Data System, and other databases.

Journal Rank:

JCR - Q2 (Instruments and Instrumentation) / CiteScore - Q1 (Instrumentation)